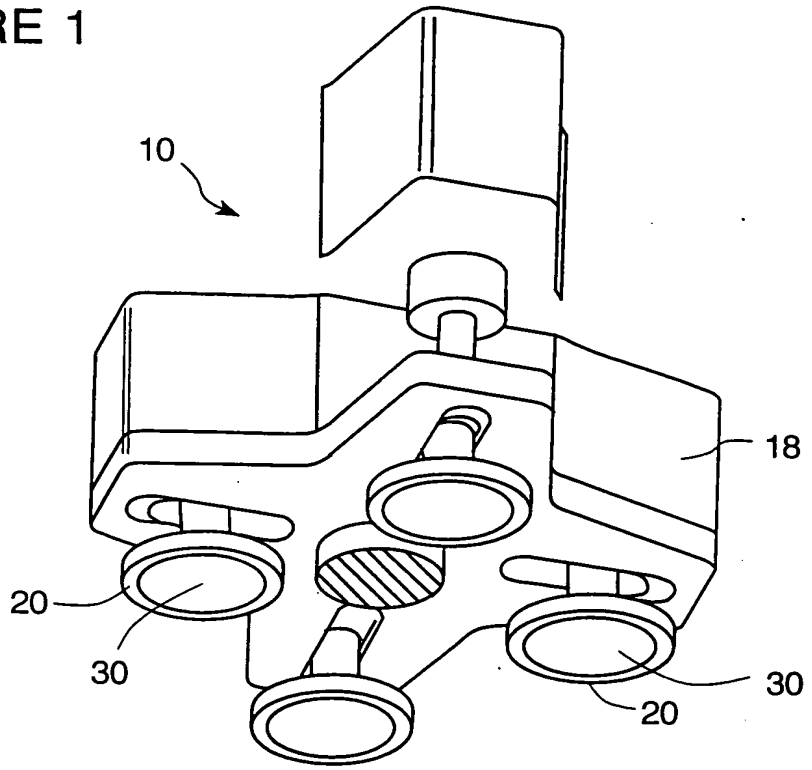
FIGURE 1



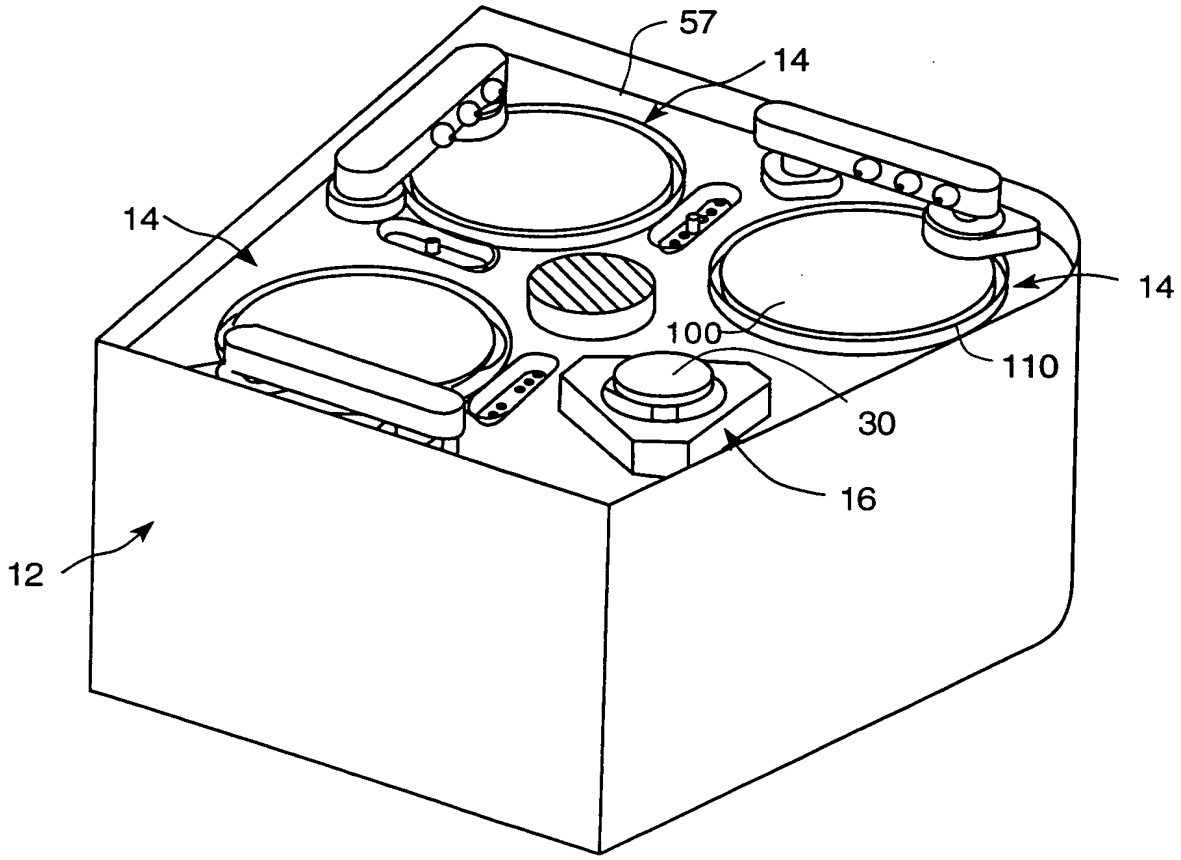


FIGURE 2

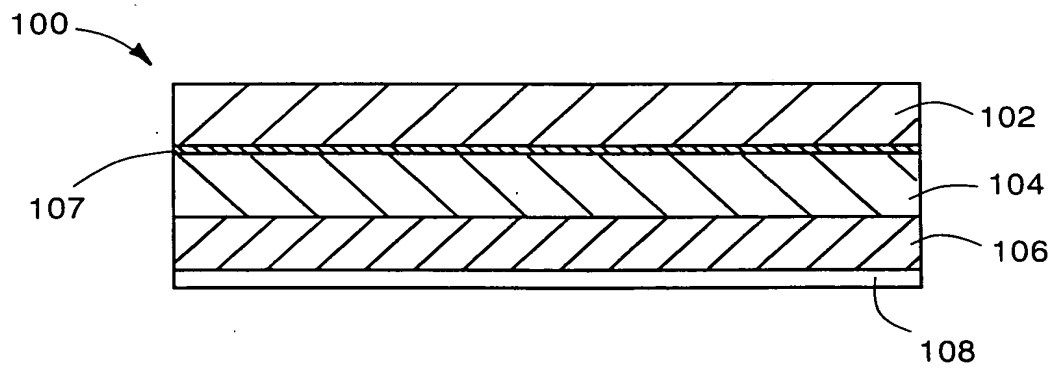


FIGURE 3

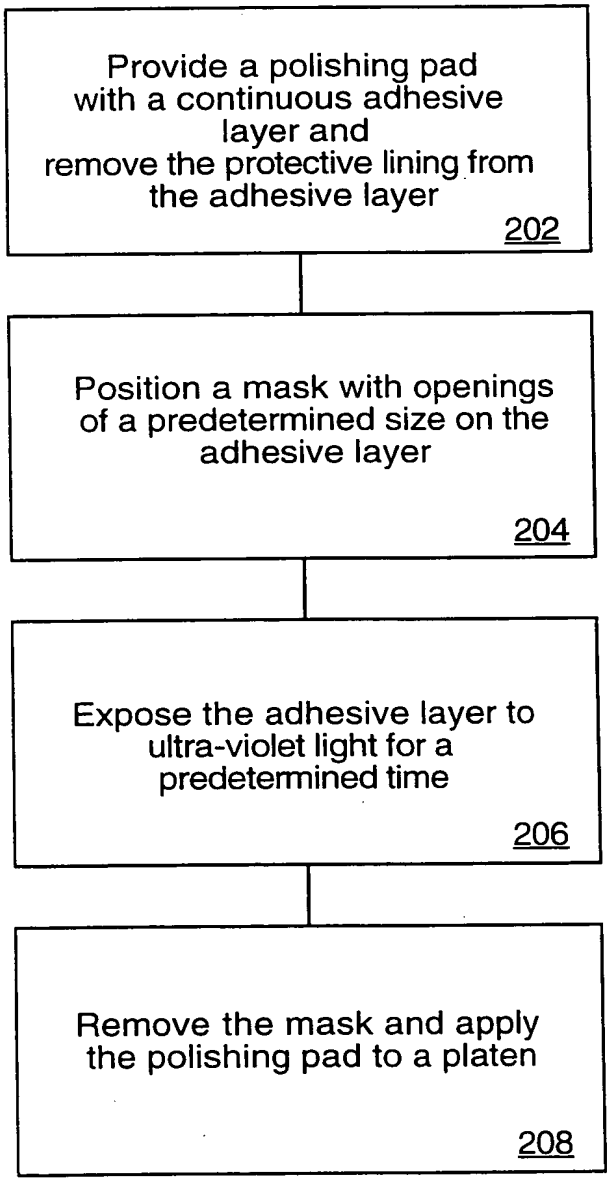

Provide a polishing pad with a continuous adhesive layer and remove the protective lining from the adhesive layer
202
Position a mask with openings of a predetermined size on the adhesive layer
204
Expose the adhesive layer to ultra-violet light for a predetermined time
206
Remove the mask and apply the polishing pad to a platen
208

FIGURE 4

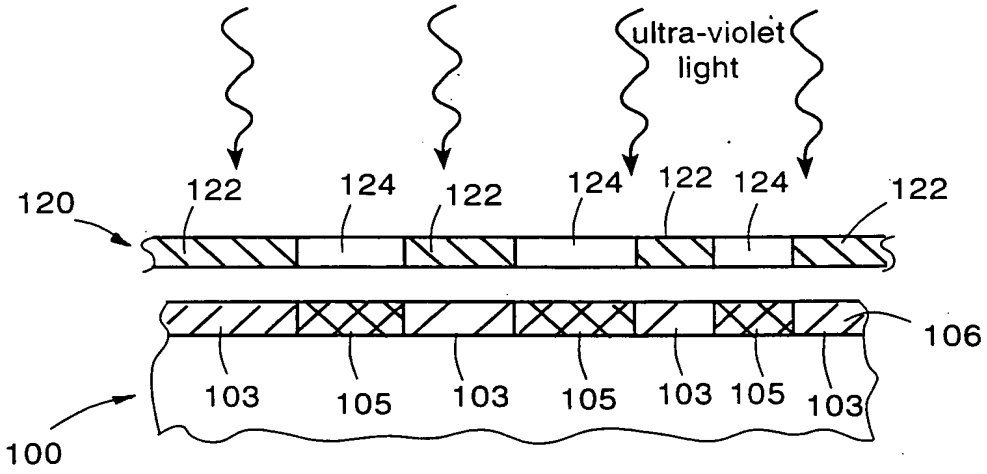

ultra-violet
light
120
122
124
122
124
122
124
122
106
103
105
103
105
103
105
103
100

FIGURE 4A

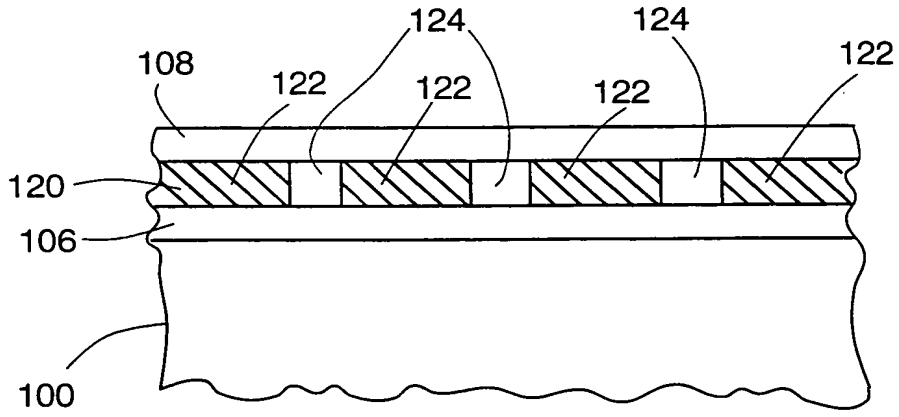


FIGURE 5

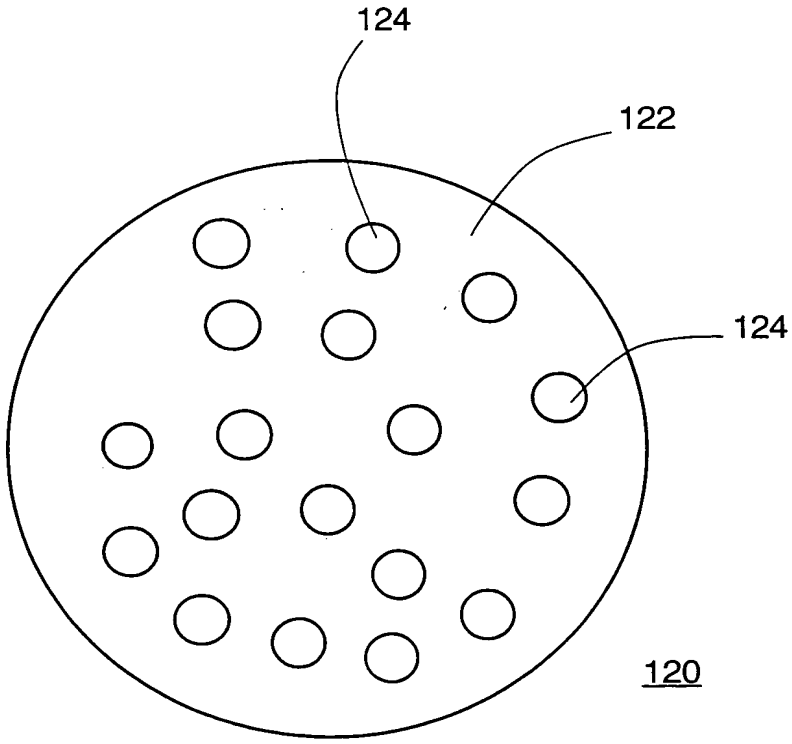


FIGURE 6

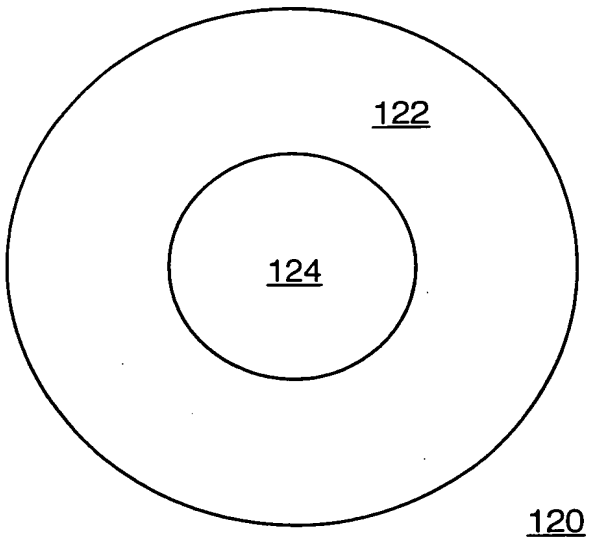


FIGURE 7

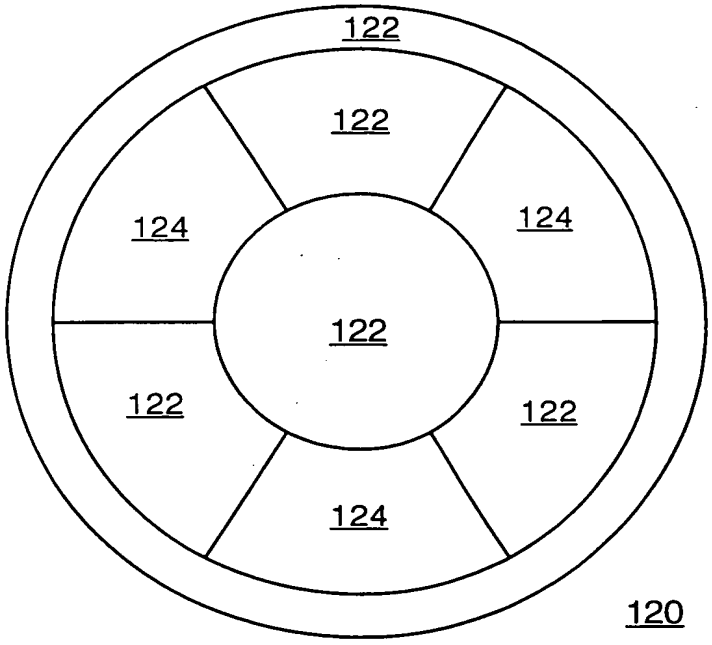
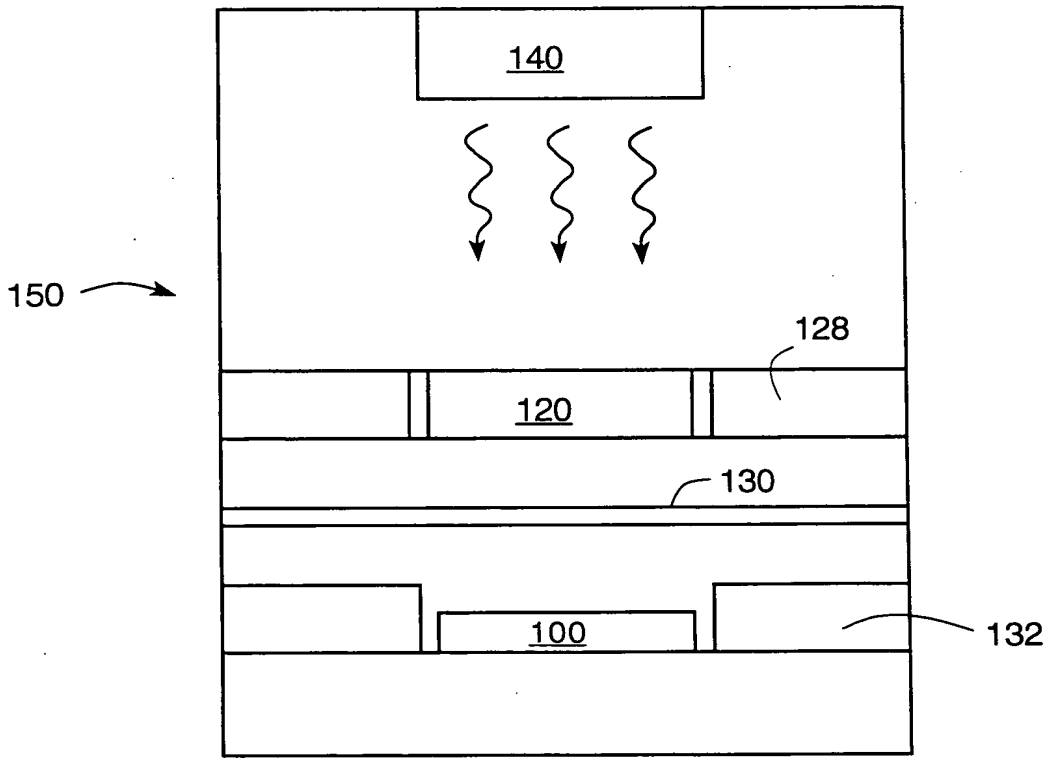



FIGURE 8